

<b>Search Notes</b>	<b>Application/Control No.</b>	<b>Applicant(s)/Patent Under Reexamination</b>
	10647297	HUH ET AL.
	<b>Examiner</b>	<b>Art Unit</b>
	Vo, Hai	1771

<b>SEARCHED</b>			
<b>Class</b>	<b>Subclass</b>	<b>Date</b>	<b>Examiner</b>
428	317.9, 143, 147, 319.3, 319.7, 402.2	8/2/2007	HV
Above to date		1/15/2008	HV

<b>SEARCH NOTES</b>			
<b>Search Notes</b>	<b>Date</b>	<b>Examiner</b>	
Nothing about liquid microelements disclosed in the two Korean docs listed in the IDS	8/2/2007	HV	

<b>INTERFERENCE SEARCH</b>			
<b>Class</b>	<b>Subclass</b>	<b>Date</b>	<b>Examiner</b>